

Surface Engineering



ISSN: 0267-0844 (Print) 1743-2944 (Online) Journal homepage: http://www.tandfonline.com/loi/ysue20

Superhydrophobicity via organophosphonic acid derivatised aluminium films

Y. Zhu, Y. M. Hu, H.-Y. Nie, W. Zhou & J. H. Yi

To cite this article: Y. Zhu, Y. M. Hu, H.-Y. Nie, W. Zhou & J. H. Yi (2016) Superhydrophobicity via organophosphonic acid derivatised aluminium films, Surface Engineering, 32:2, 114-118

To link to this article: <u>http://dx.doi.org/10.1179/1743294415Y.0000000088</u>



Published online: 12 Feb 2016.



Submit your article to this journal 🗹



View related articles

Full Terms & Conditions of access and use can be found at http://www.tandfonline.com/action/journalInformation?journalCode=ysue20

Superhydrophobicity via organophosphonic acid derivatised aluminium films

Y. Zhu¹, Y. M. Hu^{*1,2}, H.-Y. Nie³, W. Zhou¹ and J. H. Yi¹

Organophosphonic acid derivatisation on aluminium surfaces had been demonstrated to be effective for surface energy control. By following the surface energy control strategy, surperhydrophobic AI surfaces had been achieved via microcolumn pattern and dodecylphosphonic acid (DDPA) derivatisation. The water contact and sliding angles of the superhydrophobic AI surfaces were respectively 156 and 5°. Measurements confirmed that the linkage between DDPA and AI are mainly bidentate P–O–AI. The wetting properties as well as the mechanical durability of the superhydrophobic AI surfaces were tested and discussed.

Keywords: Superhydrophobicity, Dodecylphosphonic acid, Self-assembly, Water contact angle, Wetting properties

Introduction

Surface wettability depends both on surface energy and geometrical structures.^{1–4} Therefore, superhydrophobic surfaces can be fabricated via two different strategies: creation of rough structure on hydrophobic surfaces or modification of rough surfaces with low surface energy coatings.^{2,5–7} Superhydrophobic Al surfaces have generated extensive interests because of their potential applications in architectures, electric cooker liners, microelectronic mechanical systems and so forth.8-13 Since clean Al surface is intrinsically hydrophilic, both appropriate surface structure and low surface energy modification are necessary to make it superhydrophobic. In the surface construction strategy, by electrolytic and chemical etching, micro/nanostructured Al surfaces had been fabricated to achieve superhydrophobicity.14-16 The etching process has the benefits of convenience and low cost. However, the procedure control is difficult and, thus, limits quantitative analyses. Hence, in order to study the impact of surface structure on the wetting properties, accurate surface pattern has obvious science significance. In the surface modification strategy, Fluoroalkyl silane,^{14,15} Teflon,¹⁷ Perfluorooctyltriethoxysilane¹⁸ and other materials had been used to lower Al surface energy to achieve superhydrophobicity, and functions such as anti-icing and anticondensation were obtained. However, without chemical bonds linkage, the adhesion between Al and these materials is limited. In the present work, surperhydrophobic Al surfaces were prepared by microcolumn pattern and dodecylphosphonic acid (DDPA) derivatisation. We demonstrated that DDPA bonded to Al surfaces through mainly bidentate P-O-Al linkage via condensation reaction between the hydroxyl of Al and

© 2016 Institute of Materials, Minerals and Mining Published by Taylor and Francis on behalf of the Institute Received 04 February 2015; accepted 23 May 2015 DOI 10.1179/1743294415Y.0000000088 the acid headgroups. The covalent bonds between Al and organophosphonic acid headgroups provide potential applications of superhydrophobic Al surfaces due to their durability.^{19–21}

Experimental

Materials and sample preparation

Semiconductor grade single crystal *n* type Si (100) wafers were cut into 15×15 mm coupons. The coupons were cleaned by sonication in acetone for 15 min and followed by sequentially rinsing with deionised water (18.2 M Ω ; Milli-Q), drying in a N₂ stream and treating by a ultraviolet (UV)/ozone to remove residual organics.

A layer of SU-8 photoresist was spin coated onto cleaned Si substrates and patterned to microcolumn arrays via standard procedures of exposing, developing, washing and drying. Detailed processes are described in Refs. 22 and 23. An ~ 100 nm Al film was deposited on the patterned SU-8 surface by radio frequency magnetron sputtering. The samples were treated by a UV/ozone before DDPA derivatisation to remove residual organics and to oxidise the Al surfaces to a depth of ~ 3 nm simultaneously.

Crystalline DDPA powder $[CH_3(CH_2)_{11}P(= O) (OH)_2$, purity >97%] purchased from Polycarbon Industries (Devens, MA, USA) was heated to 100°C for 10 min to eliminate moisture before use. A 2 mM DDPA solution in tetrachloroethane was used to derivatise DDPA on the patterned Al surfaces. In the derivitisation procedure, the microcolumn structural Al surfaces were immersed into the DDPA solution for 5 min and followed by successive alcohol and deionised water rinsing and a final N₂ stream drying. It is worth to mention that the cleaned Al surfaces were used immediately for DDPA derivatisation since possible contamination will weaken or even block the interaction between the DDPA headgroups and the Al surfaces.

Surface roughness characterisation

Scanning electron microscopy and dynamic force mode atomic force microscopy (AFM) were conducted to

¹Faculty of Materials Science and Engineering, Kunming University of Science and Technology, Kunming 650093, China

²School of Engineering, Dali University, Dali 671003, China ³Surface Science Western, The University of Western Ontario, 999 Collip Circle, London, Ont. N6G 0J3, Canada

^{*}Corresponding author, email vongmachu@163.com

characterise the morphology of Al and DDPA/Al surfaces. Since it is difficult to measure these microcolumn surfaces by AFM, we adopted flat control samples, which were prepared under the same procedure except column patterning. The AFM images were obtained at a scan rate of $5 \,\mu m \, s^{-1}$ in ambient with relative humidity of 50%. The data points in an AFM image were typically 256×256 .

Surface chemical analysis

X-ray photoelectron spectroscopy (XPS) (Kratos AXIS ULTRA) was carried out in ultrahigh vacuum (base pressure below 10^{-9} mbar) with monochromatic Al K_{α} radiation under 15.0 kV and 150 W. Detailed experimental methods are described in Ref. 21. The binding energy was calibrated by the contaminated C 1s photoelectron peak (obtained from blank cleaned Si surface) at 284.8 eV. The deconvolution of high resolution XPS peaks has been obtained by the mixed Gaussian–Lorentzian fit after Shirley background subtraction. The XPSPEAK processing software was used to curve fitting and analyses.

Surface wetting property measurements

Sessile drop static water contact angle (WCA) measurements were conducted with a Rame'–Hart's Model 100-00 Digidrop contact angle measurement system to determine the surface wetting properties. All measurements were performed using deionised H_2O in 50% relative humidity ambient at room temperature. On each sample, at least three spots were tested, and the averaged WCA was obtained.

Results and discussion

Surface morphology

SU-8, Al/SU-8 and DDPA/Al/SU-8 surfaces showed no obvious differences in SEM images under the order of micrometre. For simplicity, we only show the images of DDPA/Al/SU-8 in Fig. 1*a*. The diameter and height of each column and the period of the column pattern are 16, 19 and 25 μ m respectively. Figure 1*b* shows the cross-section of an Al film coated on a flat SU-8 surface. The Al film was prepared under the same conditions as those in the column patterned cases. The Al/SU-8 interface is

clearly seen in Fig. 1*b*, and the thickness of the Al film was measured to be 111 nm. Hence, the thickness of the Al film was too small to influence the morphology of the column pattern.

Parts *a* and *c* in Fig. 2 are topographic images (rendered in 3D) obtained in an area of $10 \ \mu m \times 10 \ \mu m$ for the bare Al and DDPA/Al surfaces, respectively. Typical profiles, extracted from Fig. 2*a* and *c*, are shown in Fig. 2*b* and *d*. No significant morphological changes were observed between the blank Al/SU-8 and the DDPA derivatised Al/SU-8 surfaces. The 'droplets' seen in Fig. 2*a* and *c* are aggregates of Al particles. The largest aggregate seen in panel *c* reaches 300 nm in height and 3 μm in diameter. The overall root mean square roughness of the two samples was estimated to be 30–40 nm.

Surface chemical states

Figure 3 provides the XPS spectra of the DDPA/Al/SU-8 surface. In the range of 284–289 eV, the C 1s peak (Fig. 2*a*) was satisfactorily fitted and separated to two components: a tiny state at 284.86 eV with full width half maximum (FWHM) of 1.27 eV accompanied with a main state at higher binding energy of 286.49 eV with FWHM of 1.15 eV. The components correspond to adventitious carbon and C–C/C–H bonds of DDPA CH₂ groups respectively.²⁴

Multiple curve fitting solutions were used when analysing the O 1s core level lines in Fig. 3b. According to Refs. 19–21 and 25, a reasonable scheme was adopted in which O 1s was separated to two peaks: a stronger peak at 532.71 eV with FWHM of 1.90 eV represents the main contribution of the P-O-Al bonds; a peak at 534.12 eV, with FWHM of 1.74 eV, is attributed to P = O bonds. The existence of P = O bonds suggests that the bonding configuration of P-O-Al is either mono- or bidentate, rather than tridentate. The O 1s line in this spectrum does not show the highest binding energy component at \sim 538 eV, which is due to organophosphonic acid hydrogen bonding to the silicon oxide surface or to neighbouring molecules in the case of bulk octadecylphosphonic acid (which has the same headgroups as DDPA) on silicon oxide surfaces.¹⁹ The lack of this component here indicates the DDPA monolayer derivatisation on Al surfaces.



1 Images (SEM) of a DDPA/AI/SU-8 surface and b profile of sputtered AI coated flat SU-8



2 Images (AFM) of a flat AI and c DDPA/AI surfaces and b and d are their corresponding profiles



3 X-ray photoelectron spectra obtained for DDPA/AI surface: peaks of a C 1s, b O 1s, c AI 2p and dP_{2s}

Figure 3*c* shows an Al metal peak at 72.84 eV, an Al₂O₃ peak at 73.54 eV and Al–O bond peak at 75.9 eV. The Al–O bond peak corresponds to the P–O–Al component at 532.71 eV in the O 1s peak. The results agree well with the reported peak separation of $\sim 2.8 \text{ eV}$.^{20,26}

Furthermore, in consideration of the sensitive factors, the integral intensities of the P–O–Al component in O 1s and Al 2p are 15.8 and 10.6 k CPS respectively suggesting that the bonding configuration of the P–O–Al bonds are mainly bidentate.²⁷ The corresponding

schematic diagrams are shown in Fig. 4. Besides, the Al oxide layer is essential to DDPA derivatisation since it provides O to form P–O–Al bonds.

Figure 3*d* is the spectrum of P 2s. The observed P 2s binding energy is 192.91 eV. The lower binding energy peak at 180.84 eV is attributed to Al plasmon loss.¹⁹

Atomic per cent concentration (APC, in percentage) was quantitatively measured and used to determine the surface chemical composition. The APC of C, O, Al and P were 43.42, 32.08, 21.36 and 3.14 respectively. The APC ratio of C 1s/P 2s is 13.83, which approaches the expected value of 12; the deviation comes from the adventitious carbon.

Surface wetting properties

The inset in Fig. 4 is a deionised water droplet beading up on the DDPA derivatised, column patterned Al surface and shows a WCA of $156\pm 3^{\circ}$. Meanwhile, the water sliding angle (WSA) is ~5° (not shown). For a DDPA derivatised flat Al film, we detected a WCA of $115\pm 3^{\circ}$. Therefore, the superhydrophobicity observed in this case is attributed to both a hydrophobic surface and a patterned surface, which would trap air in gaps among the columns when a water droplet is placed.

In order to elaborate the impact of the surface chemistry and roughness on superhydrophobicity,^{28,29} we discuss the homogeneous wetting (Wenzel model) and heterogeneous wetting (Cassie–Baxter model) regimes. The Cassie–Baxter equation relating the WCA on a rough surface θ and an idea surface θ_0 is as follows

$$\cos \theta = r_{\rm f} f \cos \theta_0 + f - 1$$

where f is the portion of the water droplet that contacts the solid surface (thus 1-f is the air fraction). The roughness ratio r_f of the contacted portion is defined as the ratio of the true surface area to its projected one (always >1). When f=1, the Cassie–Baxter equation transfers to the Wenzel equation, describing the homogeneous wetting of water i.e. water is only in contact with the solid without air pockets trapped in the grooves. Both equations predict that when $\theta_0 > 90^\circ$, θ will become larger. However, only the Cassie–Baxter equation allows θ to be larger than 90° for $\theta_0 < 90^\circ$.

We found that the flat Al surface had a WCA $<10^{\circ}$ immediately after the UV cleaning, which is characterised as a hydrophilic surface. The column patterned



Al surface, after UV cleaning, also showed a WCA $<10^{\circ}$, suggesting that water wets both the top surface of the columns and the surface at the bottom. This is due to the fact that the surface energy was very high immediately after the UV cleaning so that water wets the whole surfaces, leaving no air pockets in the gaps between columns. Therefore, the wettability of water on such a rough surface should follow the Wenzel equation. However, since the WCA on the flat Al film was already very small (<10°), the roughness effect was thus undetectable experimentally.

Interestingly, we found that aged flat Al films had a larger contact angle of $\sim 83^\circ$, which is due to hydrocarbon adsorption. For this WCA (83°), the Wenzel equation predicts a WCA <83° on the aged column patterned Al surface. On the other hand, the Cassie-Baxter equation predicts a metastable state with a WCA $>90^{\circ}$.³⁰ In fact, the WCA we obtained on this aged, column patterned Al surface was 140°. Thus, the water droplet followed the Cassie-Baxter equation, rather than the Wenzel equation. Nevertheless, the water droplet, despite its high contact angle, was pinned on the surface, suggesting that the surface of the top of the Al coated columns was hydrophilic, with a surface energy much smaller than the cleaned one before the hydrocarbon adsorption took place. Owing to this observation, we believe that the water droplet (with WCA of $156 \pm 3^{\circ}$ and WSA of 5°) beading up on the freshly cleaned DDPA derivatised, column patterned Al surface is in the Cassie-Baxter state, which means that there are air pockets trapped among the columns.

Cycled pressure water flushing was conducted to test the mechanical durability of the superhydrophobic Al surfaces. In each cycle, the samples were continuously flushed for 5–10 min with 0.1 mPa waterspout and dried at 80°C for 1 h followed by WCA and WSA measurements. The results are shown in Fig. 5. The WCA slightly increased from 156 to 157° in the beginning 5 min. Meanwhile, the WSA has a decrease from 5 to 4°. From 5 to 45 min, the curves maintain smooth except a slight decrease in WCA from 156 to 155° at 30 min. After 45 min, the WCA decreased to 155°, while the WSA was maintained at 5°. The curve fluctuation is due to the DDPA layer changes in the flushing process. During the first 5 min, superfluous DDPA molecules residual from

Water contact/sliding angle (°) 160 155 Water contact angle 150 Water side angle 5 0 10 20 30 50 0 40 60 Water dashing time (min)

5 Water contact angle and WSA of prepared AI surfaces after pressure water flushing



the rinsing process were continuously removed. As a consequence, the surfaces showed a higher WCA and lower WSA at 5 min. In the second cycle, from 5 to 10 min, DDPA molecules located at the edge of the columns, which bonded relatively weaker to the Al surface, were removed. Up to 10 min, all unstable factors were erased, and the curves remain unchanged. The slight decrease in WCA at 30 min was tentatively attributed to measuring error since the WSA did not change at that time, and the WCA remain unchanged at 20 and 35 min respectively. Although the DDPA monolayer became to be slowly destroyed after 45 min, the durability of the super-hydrophobic Al surface was great due to the tight chemical bonds between the DDPA headgroups and the Al.

The column pattern approach adopted in the present work has its significance because of its easy control and excellent reproducibility, which may benefit fabrication of novel surface structures to achieve anisotropic WCA, superoleophobicity, etc. With an extremely rapid dip coating method recently reported,³¹ we expect that the approach to use organophosphonic acid as the surface energy control agent derivatised on Al films will accelerate the applications in making superhydrophobic surfaces.

Conclusion

Periodic microcolumn patterned Al surfaces were hydrophobilised via DDPA self-assembled monolayer derivatisation. This structured surface displayed superhydrophobicity with WCA and WSA of 156 and 5° respectively. We demonstrated that the organophosphonic acid derivatised Al film is a useful method to control the surface energy of a rough surface, which renders superhydrophobicity. The combination of Al film and organophosphonic acid derivatisation provides a simple and high throughput approach to hydrophobilise any surface as long as the Al films can be coated on it.

Acknowledgements

The authors thank Dr D. Yang for the helpful discussion. This work was supported by the National Natural Science Foundation of China (NSFC) under grant no. 21104028, the 2014 Competitive Grant Program of Oversea Returnees Research Projects and the Natural Science Foundation of Yunnan Province (grant nos. 2011FZ015 and 2011FZ051).

References

- L. Zhai, F. C. Cebeci, R. E. Cohen and M. F. Rubner: 'Stable superhydrophobic coatings from polyelectrolyte multilayers', *Nano Lett.*, 2004, 4, 1349–1354.
- L. Feng, S. H. Li, Y. S. Li, H. J. Li, L. J. Zhang, J. Zhai, Y. L. Song, B. Q. Liu, L. Jiang and D. B. Zhu: 'Super-hydrophobic surfaces: from natural to artificial', *Adv. Mater.*, 2002, 14, 1857–1860.
- 3. A. Nakajima, K. Hashimoto and T. Watanabe: 'Recent studies on super-hydrophobic films', *Monatsh. Chem.*, 2001, **13**, 31–41.
- D. Quéré: 'Fluid dynamics: impact on Everest', *Nature*, 2005, 435, 1167–1168.
- Y. C. Hong and H. S. Uhm: 'Superhydrophobicity of a material made from multiwalled carbon nanotubes', *Appl. Phys. Lett.*, 2006, 88, 244101–244103.
- Z. J. Chen, Y. B. Guo and S. M. Fang: 'A facial approach to fabricate superhydrophobic aluminum surface', *Surf. Interface Anal.*, 2010, 42, 1–6.
- D. K. Sarkar and N. Saleema: 'One-step fabrication process of superhydrophobic green coatings', *Surf. Coat. Technol.*, 2010, 204, 2483–2486.

- X. J. Feng, L. Feng, M. H. Jin, J. Zhai, L. Jiang and D. B. Zhu: 'Reversible super-hydrophobicity to super-hydrophilicity transition of aligned ZnO nanorod films', J. Am. Chem. Soc., 2004, 126, 62–63.
- Z. Guo, X. Chen, J. Li, J. H. Liu and X. J. Huang: 'ZnO/CuO hetero-hierarchical nanotrees array: hydrothermal preparation and self-cleaning properties', *Langmuir*, 2011, 27, 6193–6200.
- and self-cleaning properties', *Langmuir*, 2011, 27, 6193–6200.
 L. Hornbeck: 'The DMDTM Projection Display Chip: a MEMS-based technology', *MRS Bull.*, 2001, 26, 325–327.
- N. S. Tambe and B. Bhushan: 'Nanotribological characterization of self-assembled monolayers deposited on silicon and aluminium substrates', *Nanotechnology*, 2005, 16, 1549–1558.
- B. Bhushan: 'Adhesion and stiction: mechanisms, measurement techniques, and methods for reduction', J. Vac. Sci. Technol. B, 2003, 21B, 2262–2296.
- B. Bhushan and H. Liu: 'Characterization of nanomechanical and nanotribological properties of digital micromirror devices', *Nanotechnology*, 2004, 15, 1785–1791.
- Y. Wu and C. Zhang: 'Analysis of anti-condensation mechanism on superhydrophobic anodic aluminum oxide surface', *Appl. Therm. Eng.*, 2013, **58**, 664–669.
- I. Bernagozzi, C. Antonini, F. Villa and M. Marengo: 'Fabricating superhydrophobic aluminum: an optimized one-step wet synthesis using fluoroalkyl silane', *Colloids Surf. A*, 2014, 441A, 919–924.
- P. Li, X. Chen, G. Yang, L. Yu and P. Zhang: 'Fabrication and characterization of stable superhydrophobic surface with good friction-reducing performance on Al foil', *Appl. Surf. Sci.*, 2014, 300, 184–190.
- R. Jafari and M. Farzaneh: 'Fabrication of superhydrophobic nanostructured surface on aluminum alloy', *Appl. Phys. A*, 2011, 102A, 195–199.
- F. Y. Lv and P. Zhang: 'Fabrication and characterization of superhydrophobic surfaces on aluminum alloy substrates', *Appl. Surf. Sci.*, 2014, **321**, 166–172.
- I. Gouzman, M. Dubey, M. D. Carolus, J. Schwartz and S. L. Bernasek: 'Monolayer vs. multilayer self-assembled alkylphosphonate films: X-ray photoelectron spectroscopy studies', *Surf. Sci.*, 2006, 600, 773–781.
- E. Hoque, J. A. DeRose, P. Hoffmann, H. J. Mathieu, B. Bhushan and M. Cichomski: 'Phosphonate self-assembled monolayers on aluminum surfaces', J. Chem. Phys., 2006, 124, 174710.
- N. S. McIntyre, H. -Y. Nie, A. P. Grosvenor, R. D. Davidson and D. Briggs: 'XPS studies of octadecylphosphonic acid (OPA) monolayer interactions with some metal and mineral surfaces', *Surf. Interface Anal.*, 2005, **37**, 749–754.
- H. Lovenz, M. Despont and N. Fahrni: 'High-aspect-ratio, ultrathick, negative-tone near-UV photoresist and its applications for MEMS', *Sens. Actuators*, 1998, 64A, 33–39.
- K. Y. Lee, N. LaBianca and S. A. Rishten: 'Micromachining applications of a high resolution ultrathick photoresist', *J. Vac. Sci. Technol. B*, 1995, **13B**, (6), 3012–3016.
- 24. J. A. DeRose, E. Hoque, B. Bhushan and H. J. Mathieu: 'Characterization of perfluorodecanoate self-assembled monolayers on aluminum and comparison of stability with phosphonate and siloxy self-assembled monolayers', *Surf. Sci.*, 2008, **602**, 1360–1367.
- T. Hauffman, O. Blajiev, J. Snauwaert, C. van Haesendonck, A. Hubin and H. Terryn: 'Study of the self-assembling of n-octylphosphonic acid layers on aluminum oxide', *Langmuir*, 2008, 24, 13450–13456.
- S. Gredelj, A. R. Gerson, S. Kumar and G. P. Cavallaro: 'Characterization of aluminium surfaces with and without plasma nitriding by X-ray photoelectron spectroscopy', *Appl. Surf. Sci.*, 2001, **174**, 240–250.
- H.-Y. Nie, Mary J. Walzak and N. Stewart McIntyre: 'Delivering octadecylphosphonic acid self-assembled monolayers on a Si wafer and other oxide surfaces', J. Phys. Chem. B, 2006, 110B, 21101–21108.
- A. Marmur: 'Wetting on hydrophobic rough surfaces: to be heterogeneous or not to be?', *Langmuir*, 2003, 19, 8343–8348.
- T. Darmanin and F. Guittard: 'Recent advances in the potential applications of bioinspired superhydrophobic materials', *J. Mater. Chem. A*, 2014, 2A, 16319–16359.
- L. Cao, H. -H. Hu and D. Gao: 'Design and fabrication of microtextures for inducing a superhydrophobic behavior on hydrophilic materials', *Langmuir*, 2007, 23, 4310–4314.
- 31. D. H. Chen, H. K.-Y. Wu, S. Naderi-Gohar, Y. L. Wu, Y. N. Huang and H.-Y. Nie: 'An extremely rapid dip-coating method for self-assembly of octadecylphosphonic acid and its thermal stability on an aluminum film', *J. Mater. Chem. C*, 2014, 2C, 9941–9948.